Electronic Acknowledgement Receipt

EFS ID:	1398506
Application Number:	10678908
International Application Number:	
Confirmation Number:	2225
Title of Invention:	Process for passivating polysilicon and process for fabricating polysilicon thin film transistor
First Named Inventor/Applicant Name:	Ching-Wei Lin
Customer Number:	34283
Filer:	Nelson Alejandro Quintero
Filer Authorized By:	
Attorney Docket Number:	10112971
Receipt Date:	22-DEC-2006
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Application Type:	Utility

Payment information:

Submitted with Payment	no

File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1		10112971-P122246NAQ-AMEND-060925.pdf	81284	yes	6

	Multipart Description/PDF files in .zip description		
	Document Description	**Start**	**End**
	Amendment After Final	1	1
	Claims	2	4
	Applicant Arguments/Remarks Made in an Amendment	5	6
Warnings:			
Information:			
	Total Files Size (in bytes):	81284	

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New Applications Under 35 U.S.C. 111
If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371
If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.